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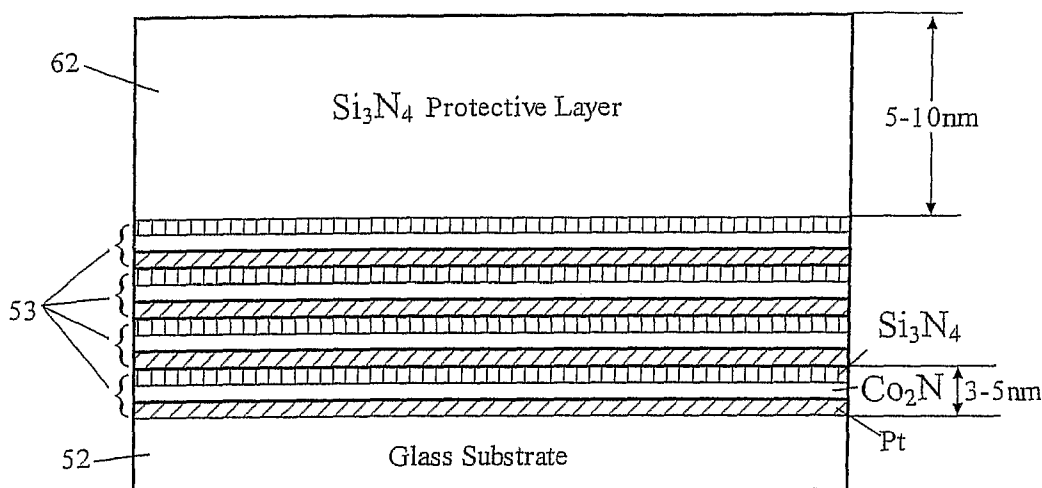
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[Continued on next page]

(54) Title: METHOD FOR MAKING A NANO-PARTICULATE MEDIUM



(57) Abstract: In a method for making a nano-particulate medium, platinum, silicon nitride and a nitride of a magnetic element which will disassociate under thermal processing in a vacuum are sputtered onto a substrate in predetermined quantities, the sub-
strate is subjected to a rapid thermal-processing operation in a vacuum, in which the substrate is raised over a given period of time
to a temperature at which the nitride of the magnetic element disassociates, releasing nitrogen by diffusion and leaving behind the
magnetic element, and the substrate is allowed to cool. The magnetic element alloys with the platinum to form particles which are
substantially mono-disperse and substantially uniformly distributed in the silicon nitride. The alloying process takes place imme-
diately the nitride of the magnetic element disassociates. The magnetic element is preferably cobalt and the substrate is preferably
also raised to a temperature which allows the formation of a PtCo alloy in a tetragonal crystalline form.

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